

One Day Seminar on Technological Advancements in Maskless Lithography and Plasma Etching



14th, Sep. 2026



9 AM - 3.00 PM


 Lalit Giri Building, Ground Floor, Room L03S
 (Third Room), IIT Bhubaneswar

AGENDA

Time	Presentation	Speaker
9 – 9.20 AM	Registrations	NA
9.20 - 9.30 AM	Welcome Note	Labindia Instruments
9.30 – 9.45 AM	Semiconductor - Emerging Industry	Prof. Shreepad Karmalkar, Director, IIT Bhubaneswar
9.45 - 10 AM	Labindia Introduction	Mr. Anoop Thapliyal, Sr. GM. Products, Labindia Instruments
10.00 – 10.40 AM	Maskless lithography, from table-top to industrial systems	Mr. Dominique Colle, Sales Manager, Heidelberg Instruments
10.40 – 10.50 AM	Tea Break	
10.50 AM – 11.30 AM	SENTECH: Experts in Plasma Process Technology and Thin-Film Metrology	Mr. Thomas Tatro, Application Engineer, SENTECH Instruments
11.30 AM – 12.15 PM	Empowering microfabrication research with the DWL 66+	Mr. Dominique Colle, Sales Manager, Heidelberg Instruments
12.15 – 1.00 PM	Advanced Plasma Etching of Silicon and III-V Compound Semiconductors Using SENTECH Etching Technology	Mr. Thomas Tatro, Application Engineer, SENTECH Instruments
1.00 PM – 2.00 PM	Lunch Break	
2.00 – 2.30 PM	Lithography in advanced device fabrication	Dr. Dipjyoti Das, Assistant Professor, SECS, IIT Bhubaneswar
2.30 – 3 PM	Closing remarks & group photo	

Last Date of Registration
Thursday, 10th September, 2026

Pre-registration is mandatory to attend the seminar.



REGISTER HERE



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For any queries, please contact : **Dr. Biplab Hazra - 9564074664**